

United States Patent and Trademark Office



UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/762,164	01/21/2004	Liang-Gi Yao	TS02-246	3763
7590 08/11/2005			EXAMINER	
STEPHEN B.		ERDEM, FAZLI		
28 DAVIS AVENUE POUGHKEEPSIE, NY 12603			ART UNIT	PAPER NUMBER
	, -		2826	
			DATE MAILED: 08/11/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

1		Application No.	Applicant(s)					
Office Action Summary		10/762,164	YAO ET AL.					
		Examiner	Art Unit					
		Fazli Erdem	2826					
	The MAILING DATE of this communication a	ppears on the cover shee	t with the correspondence a	ddress				
Period fo	• •	N V IC CET TO EVOIDE	2 MONTH(S) EDOM					
THE - External after - If the - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REF MAILING DATE OF THIS COMMUNICATION nsions of time may be available under the provisions of 37 CFR SIX (6) MONTHS from the mailing date of this communication. It period for reply specified above is less than thirty (30) days, a reperiod for reply is specified above, the maximum statutory perion to reply within the set or extended period for reply will, by state reply received by the Office later than three months after the mailed patent term adjustment. See 37 CFR 1.704(b).	I. 1.136(a). In no event, however, ma pply within the statutory minimum o d will apply and will expire SIX (6) ute, cause the application to becom	y a reply be timely filed If thirty (30) days will be considered time MONTHS from the mailing date of this BE ABANDONED (35 U.S.C. § 133).	aly. communication.				
Status								
1) 又	Responsive to communication(s) filed on 26	May 2005.						
,	This action is FINAL . 2b) This action is non-final.							
3)								
Disposit	ion of Claims							
5)⊠ 6)⊠ 7)□	4) ☐ Claim(s) 20-22 and 24-41 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) ☐ Claim(s) 28-41 is/are allowed. 6) ☐ Claim(s) 20-22 and 24-27 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or election requirement.							
	ion Papers	ror election requirement.						
• -	·	nor						
9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.								
10)	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).								
11)	The oath or declaration is objected to by the	Examiner. Note the attac	ched Office Action or form F	°TO-152.				
Priority (under 35 U.S.C. § 119							
a)	Acknowledgment is made of a claim for forei All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority docume application from the International Bure See the attached detailed Office action for a light	ents have been received. ents have been received riority documents have be eau (PCT Rule 17.2(a)).	in Application No een received in this Nationa	al Stage				
Attachmen	t(s)							
1) 🛛 Notic	ce of References Cited (PTO-892)		ew Summary (PTO-413)					
3) X Infor	ce of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/0 er No(s)/Mail Date <u>03/04 and 07/2005</u> .		No(s)/Mail Date of Informal Patent Application (P	ГО-152)				

Application/Control Number: 10/762,164 Page 2

Art Unit: 2826

Allowable Subject Matter

1. Claims 28-41 allowed.

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 20-22 and 24-27 rejected under 35 U.S.C. 103(a) as being unpatentable over Yu et al. (6,784,101) in view of Rim (6,603,156) further in view of Ward et al. (2005/0132952)

Regarding Claims 20-22 and 24-27, Yu et al. disclose formation of high-k gate dielectric layers for MOS devices fabricated on strained lattice semiconductor substrates with minimized stress relaxation where in Fig. 7 a semiconductor substrate comprising a strained lattice semiconductor layer at an upper surface and high-k dielectric layer 6 and semiconductor gate/device structure 8 disclosed over the high-k dielectric layer. Yu et al. fail to disclose the required epi-silicon structure, the required type of high-k dielectric layer, the required epi layer dislocation density and the required epi layer thickness However, Rim discloses a strained silicon on insulator structures wherein Fig. 1, layer 12 is epi-silicon layer. Furthermore, Rim discloses the required type of high-k dielectric layer in paragraph 14. Ward et al. disclose a semiconductor alloy with surface rougness and method of making the same where in claims 15, 16, and 20 the required epi layer dislocation density is disclosed and in claim 9 the required epi layer thickness is disclosed.

Application/Control Number: 10/762,164 Page 3

Art Unit: 2826

It would have been obvious to one of having ordinary skill in the art at the time the invention was made to include the required epi-silicon layer, the required type of gate dielectric, the required epi layer dislocation density and the required epi layer thickness in Yu et al. as taught by Rim and Ward et al. respectively, in order to have a semiconductor device with increased performance.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Fazli Erdem whose telephone number is (571) 272-1914. The examiner can normally be reached on M - F 8:00 - 5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nathan Flynn can be reached on (571) 272-1915. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

FE

August 5, 2005

EVAN PERT RIMARY EXAMINER